

REMARKS

Claims 1-16 remain pending in the application. The Examiner is respectfully requested to reconsider and withdraw the rejections in view of the amendments and remarks contained herein.

REJECTION UNDER 35 U.S.C. § 103

Claims 1-16 stand rejected under 35 U.S.C. § 103(a) as being unpatentable over Hashimoto (U.S. Patent No. 6,475,896 B1) in view of Kim et al. (U.S. Patent No. 6,853,433 B2). This rejection is respectfully traversed.

The office action asserts that Hashimoto discloses forming a semiconductor device with a dielectric layer 22 on portions in the lines where outer electrodes are connected to form a capacitor, after the step of forming the wiring layer (see Fig. 2E), and teaches all features of the present invention except for forming the dielectric layer by applying dielectric liquid by an inkjet method. However, Applicant respectfully points out that the dielectric layer 22 of Hashimoto is quite different from the dielectric layer defined in the claims of the present application.

The layer 22 of Hashimoto is a photoresist layer which is partially removed later (Fig. 2D) to form a seat 24 (Fig. 2E) and finally completely removed (Fig. 3B). See column 10, line 54 to column 11, line 15. In contrast, the dielectric layer defined in the claims of the present application is not such a photoresist layer but rather a layer 104 formed between a wiring layer 16 and an outer electrode 24a (see Fig. 5D), so as to constitute a capacitor. Further, Hashimoto does not disclose a semiconductor device with an inductor as defined in the present claims 7 to 13.

A feature of the present invention is that a capacitor or an inductor is formed over a stress relief layer by applying dielectric liquid or conductive liquid by an inkjet method. This is not described or suggested in the prior art.

In view of the foregoing, it can be appreciated that Hashimoto and Kim fail to teach or suggest the subject matter of independent claims 1, 7, 14 and 15. Hashimoto and Kim therefore also fail to teach or suggest the subject matter of dependent claims 2-6, 8-13 and 16. Accordingly, reconsideration and withdrawal of these rejections are respectfully requested.

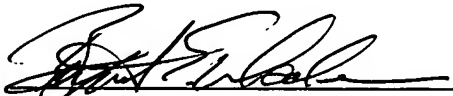
CONCLUSION

It is believed that all of the stated grounds of rejection have been properly traversed, accommodated, or rendered moot. Applicant therefore respectfully requests that the Examiner reconsider and withdraw all presently outstanding rejections. It is believed that a full and complete response has been made to the outstanding Office Action, and as such, the present application is in condition for allowance. Thus, prompt and favorable consideration of this amendment is respectfully requested.

If the Examiner believes that personal communication will expedite prosecution of this application, the Examiner is invited to telephone the undersigned at (248) 641-1600.

Respectfully submitted,

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